## Infrared Study of Reaction Between Alkoxysilanes and Silica

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WHILE trimethoxysilanes are widely used for adherence of polymers to glass, the nature of the interfacial bonding to glass remains unknown.<sup>1</sup>



Infrared spectra of various materials on silica of high surface area: A, silica alone; B, methyltrimethoxysilane; C, allyltrimethoxysilane; D, methyltrichlorosilane.

<sup>2</sup> T. H. Elmer, I. D., Chapman and M. E. Nordberg, J. Phys. Chem., 1962, 66, 1517.

We now present evidence that a siloxane bond (Si-O-Si) is formed between a trimethoxysilane and amorphous silica.

Infrared examination (Fig. 1; curve A) of high surface silica ( $\sim 200 \text{ m.}^2/\text{g.}$ ) dried at 500°c showed a strong adsorption band at 3715 cm.<sup>-1</sup> assigned to the OH stretching frequency of essentially free SiOH surface groups.<sup>2</sup> The dried silica was refluxed with 0.012-0.022M-toluene solutions of the silanes  $[RSi(OMe)_3]$  where R = Me,  $CH_2: CH \cdot CH_2$ or  $CH_2 \cdot O \cdot CH \cdot CH_2 \cdot O \cdot [CH_2]_3 \cdot ]$ , filtered, and dried at 150°. The infrared spectra of the treated silicas (Fig. 1; curves B and C) show eradication of the silanol band. Both spectra also exhibit C-H stretching bands around 2900 cm.-1, further substantiating the existence of the silane on the silica. Treatment of dried silica with toluene, methanol, or propanol, the last two representing excellent hydrogen-bonding agents, did not materially alter the location or intensity of the silanol band. The spectra of the alcohol-treated silica did have C-H stretching bands indicating their presence on the silica. When chloride was substituted for the methoxyls, *i.e.*, Cl<sub>a</sub>SiMe, the silanol surface groups were removed (Fig. 1; curve D).

<sup>&</sup>lt;sup>1</sup> K. A. F. Schmidt, Glastech. Ber., 1964, 37, 1.

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This evidence leads to the conclusion that trimethoxysilanes react, under these conditions, with surface silanol groups by some mode other than hydrogen bonding. Probably the reaction is a condensation to yield a siloxane bond:

 $\begin{array}{l} \mathrm{RSi(OMe)}_{\mathtt{3}} + \mathrm{HOSi} \; (\mathrm{surface}) \rightarrow \\ \mathrm{RSi(OMe)}_{\mathtt{3}} \cdot \mathrm{OSi} \; (\mathrm{surface}) \; + \; \mathrm{MeOH}. \end{array}$ 

The similar reaction of an alkylsilanol with an

<sup>3</sup> B. Smith, Svensk Kem Tidsk., 1955, 67, 421.

alkoxysilane to yield a siloxane bond has been previously reported.<sup>3</sup>

The adsorption bands at 2950 cm.<sup>-1</sup> and 2850 cm.<sup>-1</sup> present in the methyltrimethoxysilane (curve B) and absent from methyltrichlorosilane (curve D) indicates that there are methoxy-groups either adsorbed on the surface or unchanged. Exposure to water readily removes the methoxy-groups.

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